

L Number	Hits	Search Text	DB	Time stamp
1	135429	perfume or dye or laquer	USPAT; US-PGPUB	2003/05/02 12:59
2	210846	formamide of acetamide or formohydrazide	USPAT; US-PGPUB	2003/05/02 13:10
3	1668	(perfume or dye or laquer) same (formamide of acetamide or formohydrazide)	USPAT; US-PGPUB	2003/05/02 13:00
4	151806	silicone	USPAT; US-PGPUB	2003/05/02 13:00
5	147	((perfume or dye or laquer) same (formamide of acetamide or formohydrazide)) and silicone	USPAT; US-PGPUB	2003/05/02 13:00
6	17565	palmitate	USPAT; US-PGPUB	2003/05/02 13:00
7	23	((((perfume or dye or laquer) same (formamide of acetamide or formohydrazide)) and silicone) and palmitate	USPAT; US-PGPUB	2003/05/02 13:04
8	19147	lacquer	USPAT; US-PGPUB	2003/05/02 13:05
9	2468	(formamide of acetamide or formohydrazide) and lacquer	USPAT; US-PGPUB	2003/05/02 13:05
10	67	(formamide of acetamide or formohydrazide) same lacquer	USPAT; US-PGPUB	2003/05/02 13:05
11	125	nail adj lacquer	USPAT; US-PGPUB	2003/05/02 13:11
12	13	(formamide of acetamide or formohydrazide) and (nail adj lacquer)	USPAT; US-PGPUB	2003/05/02 13:10
13	15228	formamide of acetamide or formohydrazide	USOCR	2003/05/02 13:11
14	40	nail adj lacquer	USOCR	2003/05/02 13:11
15	0	(formamide of acetamide or formohydrazide) and (nail adj lacquer)	USOCR	2003/05/02 13:11
16	4117	remover	USOCR	2003/05/02 13:11
17	18435	nail	USOCR	2003/05/02 13:11
18	155	remover same nail	USOCR	2003/05/02 13:11
19	10820	polish	USOCR	2003/05/02 13:12
20	120	remover same polish	USOCR	2003/05/02 13:12
21	0	(formamide of acetamide or formohydrazide) and (remover same polish)	USOCR	2003/05/02 13:12

428/539 ; 96/119R ; 260/45.75N ; 423/511R ; 8/4 ; 8/74 ;
430/572 ; 428/500 ; 428/411 ; 430/17 ; 430/216 ; 430/372 ;
; 430/517 ; 430/551 ; 430/559 ; 430/561

REF-CITED:

PAT-NO	U.S. PATENT DOCUMENTS	
US-CL	ISSUE-DATE	PATENTEE-NAME
4050938	September 1977	Smith et al.
96/84R	N/A	N/A

OTHER PUBLICATIONS

Muller et al., Chem. Comm., p. 65, 1971.

ART-UNIT: 166

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ABSTRACT:

A method of stabilizing organic substrate materials having an absorption maximum in the wavelength region of about 300 nm to about 800 nm to light which comprises making coexist with the organic substrate at least one metal complex salt represented by the following general formula (I): ##STR1## wherein Cat represents a divalent or a monovalent cation, and n is 1 or 2. A photographic material thus stabilized is also disclosed.

16 Claims, 0 Drawing figures

Exemplary Claim Number: 8

BRIEF SUMMARY:

(1) BACKGROUND OF THE INVENTION

(2) 1. Field of the Invention

(3) The present invention relates to the stabilization of organic substrate materials to exposure to light and particularly, to the stabilization or organic dyestuffs for exposure to light. More particularly, the present invention relates to stabilizing organic substrate materials in the form of photographic dye images and to novel photographic elements so